thin second spacers disposed adjacent to opposite sides of said thin first spacers wherein said thin second spacers are recessed below said conductive layer; thin third spacers disposed adjacent to opposite sides of said thin second spacers wherein said thin third spacers are recessed below said conductive layer; and,

thick fourth spacers disposed adjacent to opposite sides of said thin third spacers wherein said thick fourth spacers are recessed below said conductive layer.

- 32. (Once Amended) The gate electrode of claim 31 wherein said insulative layer comprises an oxide.
- 33. (Once Amended) The gate electrode of claim 32 wherein said gate layer comprises a polysilicon.
- 34. (Once Amended) The gate electrode of claim 33 wherein said conductive layer comprises a polycide.
- 35. (Once Amended) The gate electrode of claim 34 wherein said thin first spacers comprise an oxide.
- 36. (Once Amended) The gate electrode of claim 35 wherein said thin second spacers comprise a nitride.

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- 37. (Once Amended) The gate electrode of claim 36 wherein said thin third spacers comprise an oxide.
- 38. (Once Amended) The gate electrode of claim 37 wherein said thick fourth spacers comprise a nitride.
- 39. (Once Amended) The gate electrode of claim 38 wherein said polycide comprises titanium salicide (TiSi₂).